



Docket No.: M4065.0278/P278
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Kevin L. Beaman, et al.

Application No.: 09/653,281

Group Art Unit: 2815

Filed: August 31, 2000

Examiner: J. Nguyen

For: USE OF ATOMIC OXIDATION FOR
FABRICATING OF OXIDE-NITRIDE-
OXIDE STACK FOR FLASH MEMORY
DEVICES

TECHNICAL CENTER
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RESPONSE TO RESTRICTION REQUIREMENT

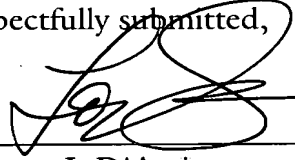
Commissioner for Patents
Washington, DC 20231

Dear Sir:

In response to the restriction requirement set forth in the Office Action mailed September 24, 2001 (Paper No. 5), Applicant hereby provisionally elects, without traverse, Group II, Claims 1-45 for continued examination.

Dated: October 10, 2001

Respectfully submitted,

By 
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